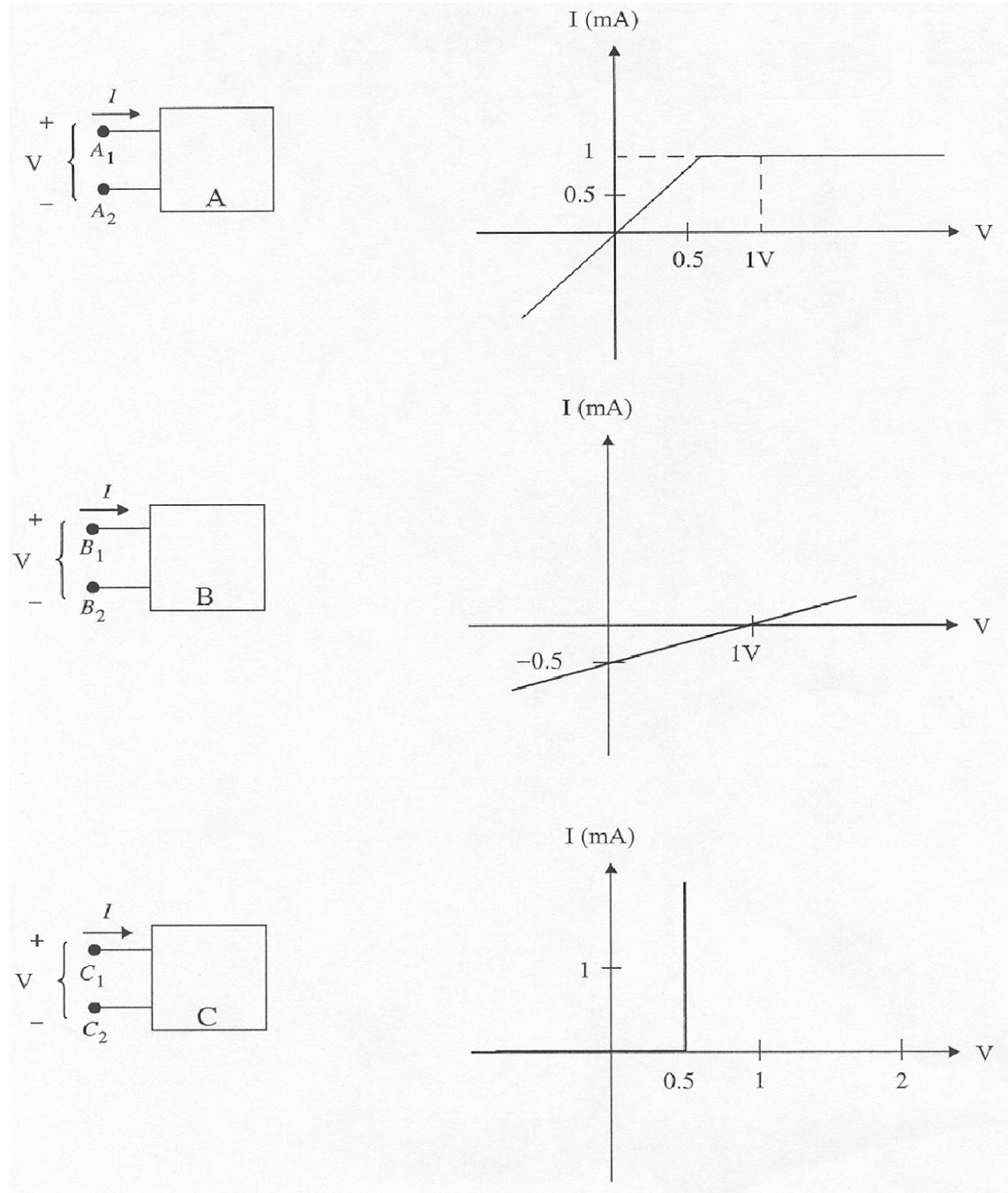


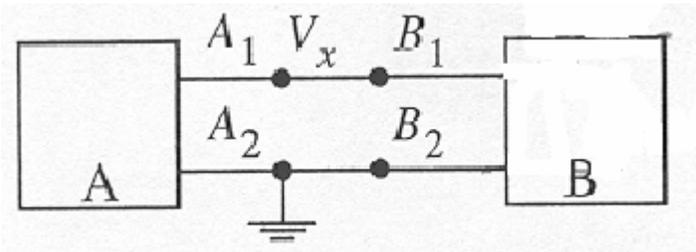
EECS 40 – MIDTERM #2
Professor Oldham
Fall 2000

Problem 1 (12 points)

The boxes A, B, C have the following I-V characteristics:

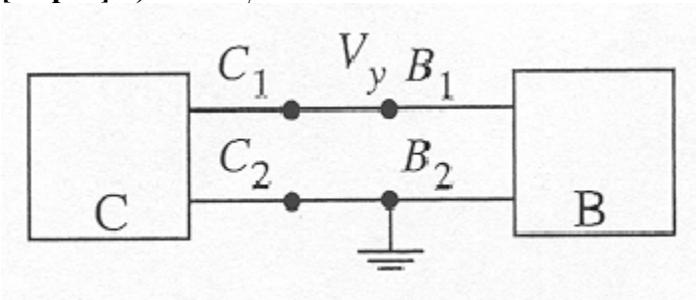


[10 pts.] a) Find V_x .



$V_x =$ _____

[10 pts.] b) Find V_y .

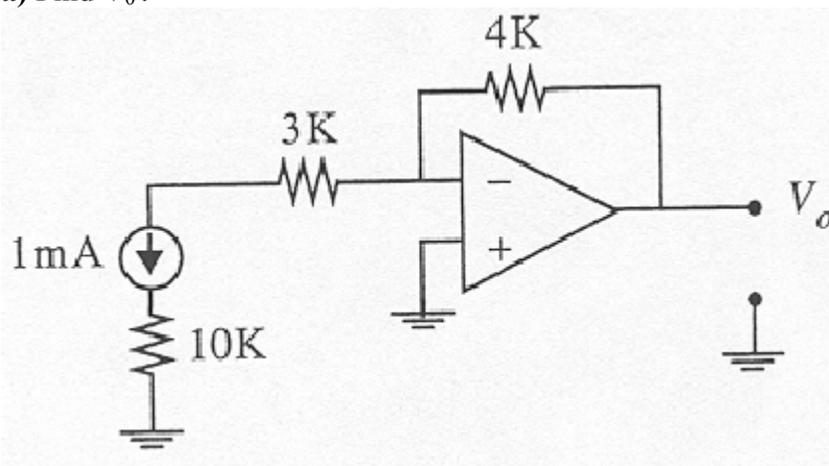


$V_y =$ _____

Problem 2 (12 points)

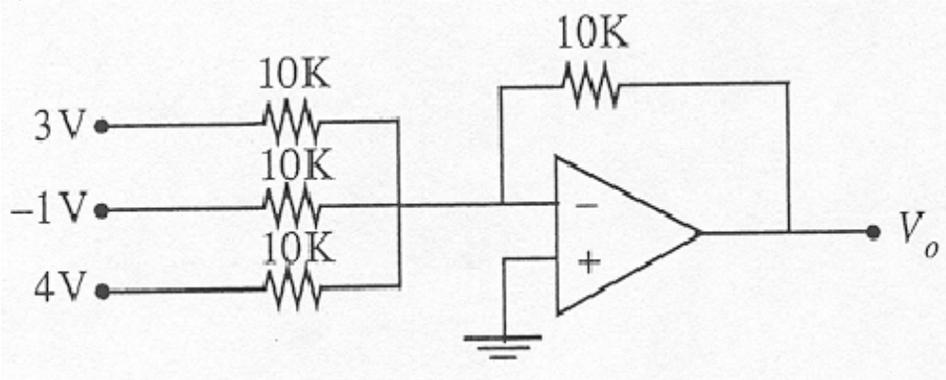
In this problem, assume that the op-amps are nearly ideal but with output voltages limited by $\pm 5V$ rails.

a) Find V_o .



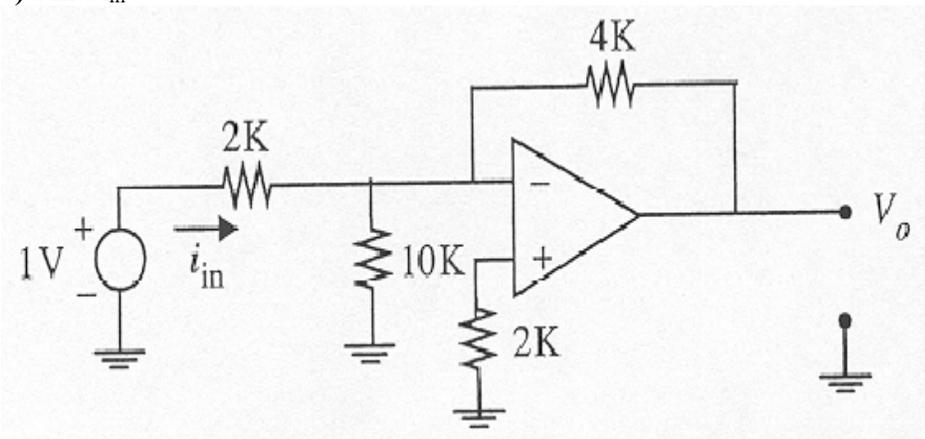
$V_o =$ _____ (V)

b) Find V_o .



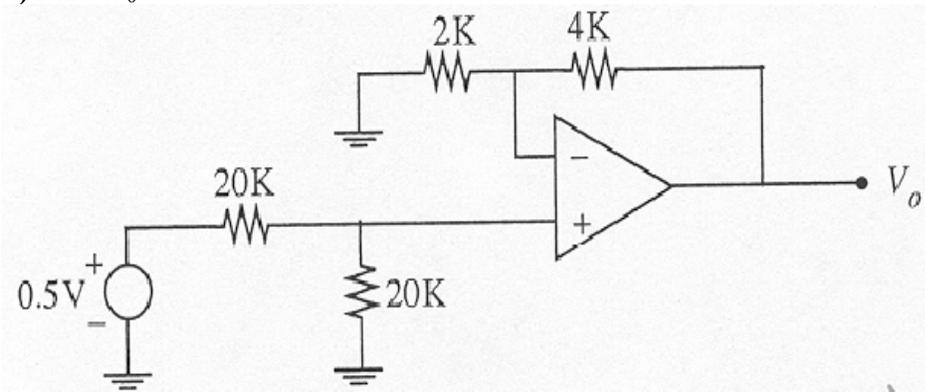
$V_o = \underline{\hspace{2cm}}$ (V)

c) Find i_{in} .



$i_{in} = \underline{\hspace{2cm}}$ (mA)

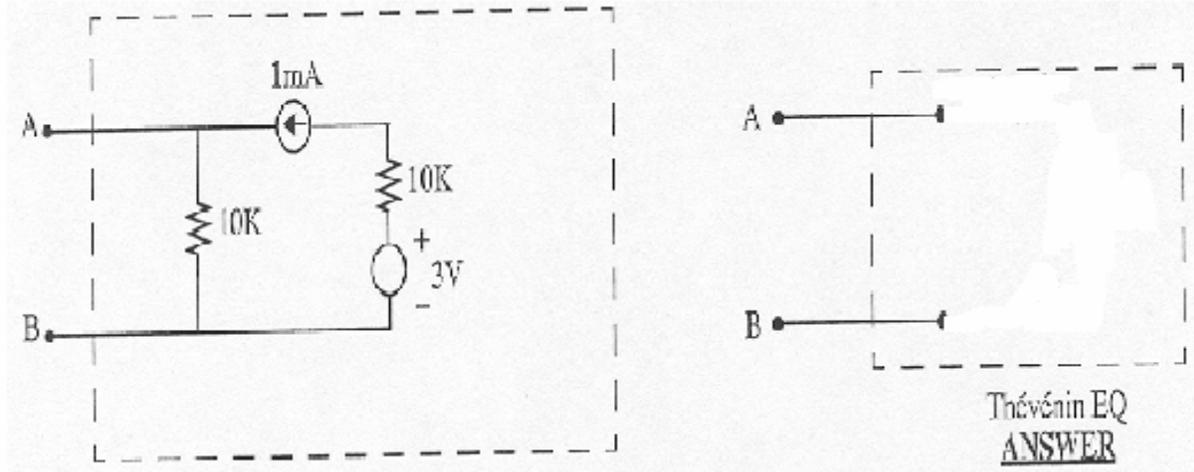
d) Find V_o .



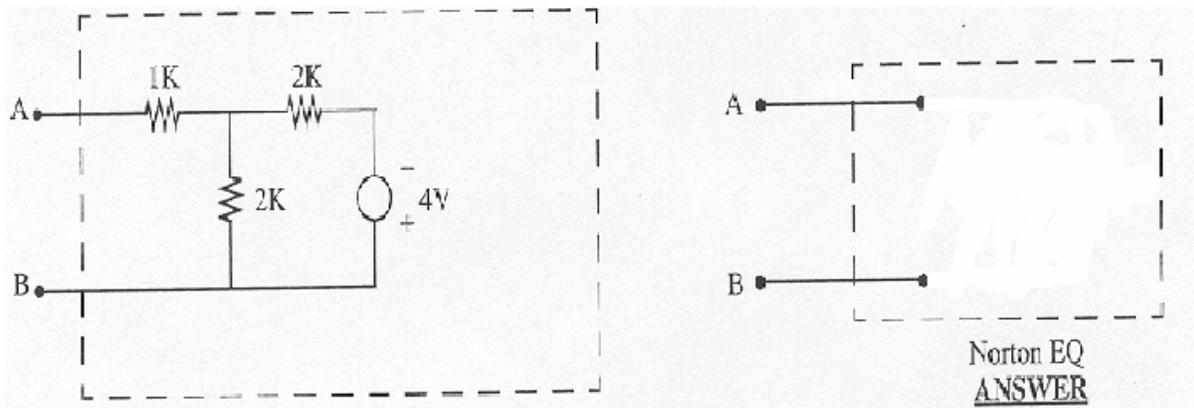
$V_o = \underline{\hspace{2cm}}$ (V)

Problem 3 (10 points)

[5 pts.] a) Find the Thevenin Equivalent circuit of the stuff in the box. Draw this Thevenin circuit in the answer box. **Note:** No credit unless the circuit is drawn in the answer box.



[5 pts.] b) Find the Norton Equivalent circuit of the stuff in the box. Draw this Norton circuit in the answer box. Again, no credit unless the circuit is drawn in the answer box.



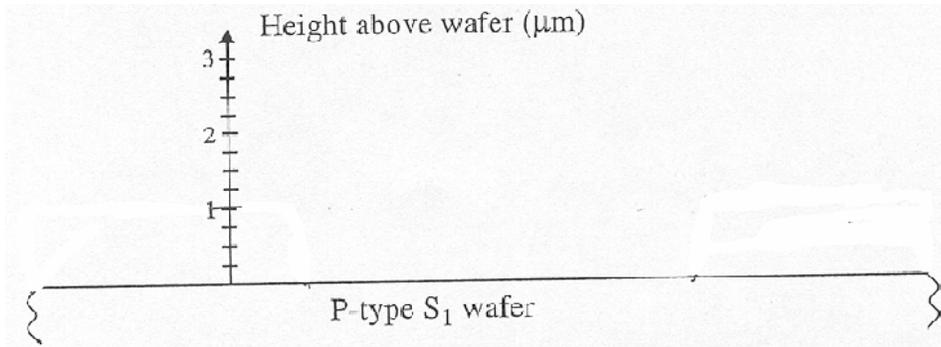
Problem 4 (16 points)

Consider the following process that refers to the figure on the opposite page.

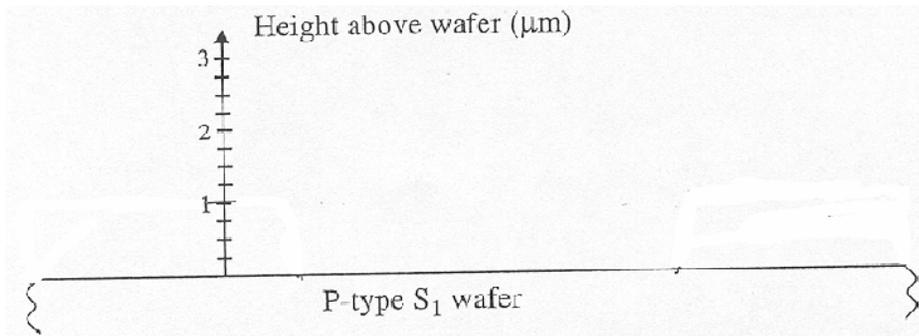
1. Start with p-type wafer.
2. Deposit 1 μ m (1000nm) oxide.
3. Deposit 0.5 μ m polysilicon. ("Poly 1")
4. Pattern polysilicon with mask (P1). (clearfield)
5. Pattern oxide with mask (OX). (darkfield)
6. Deposit 50nm oxide
7. Deposit 0.5 μ m polysilicon ("poly 2")

8. Pattern poly 2 with mask (P2). (clearfield)
9. Implant donors $10^{14} / \text{cm}^2$ and anneal to depth of $0.25 \mu\text{m}$
10. Deposit $0.5 \mu\text{m}$ oxide
11. Pattern oxide with mask (C). (darkfield)
12. Deposit $0.5 \mu\text{m}$ Al
13. Pattern Al with mask (M). (clearfield)

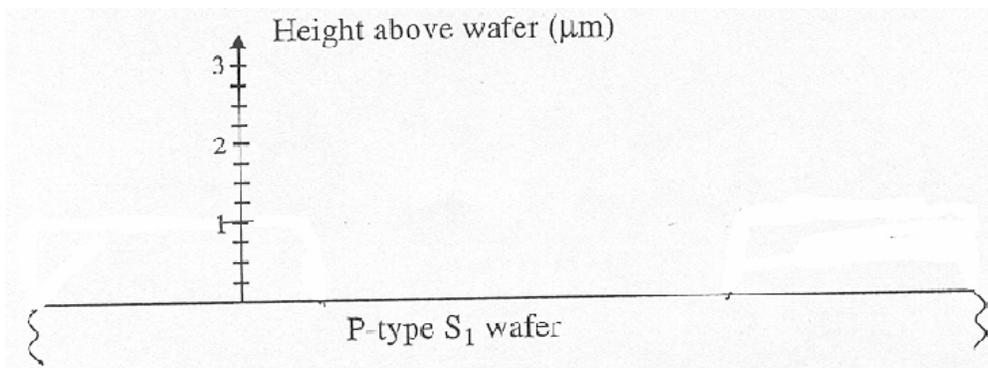
[5 pts.] a) Show cross-section A-A after completion of Step 5.



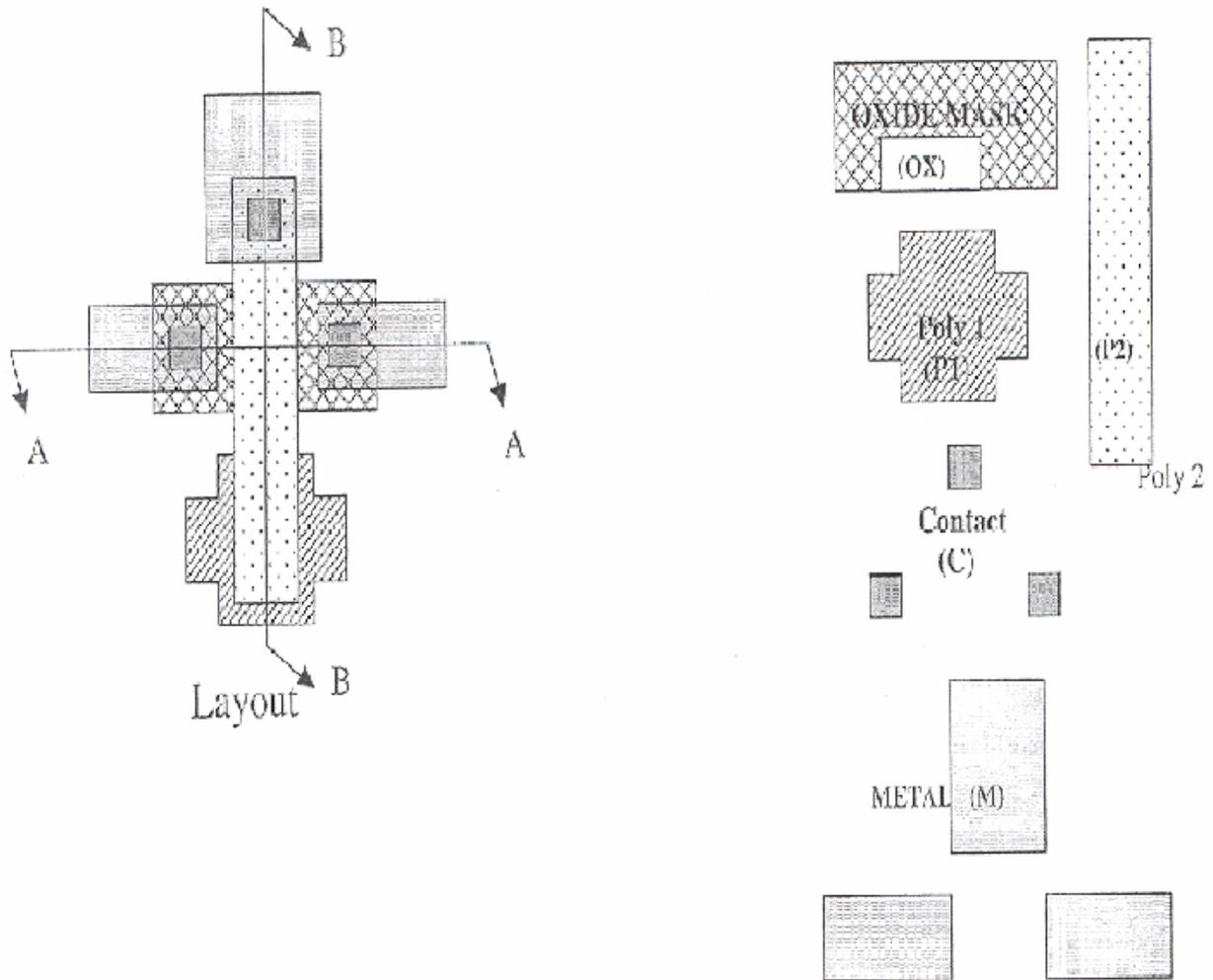
[5 pts.] b) Show cross-section B-B after completion of Step 9.



[5 pts.] c) Show cross-section B-B after completion of Step 12.



Problem 4 Figure



Problem 5 (12 points)

Assume in this problem that all diodes are perfect rectifiers.

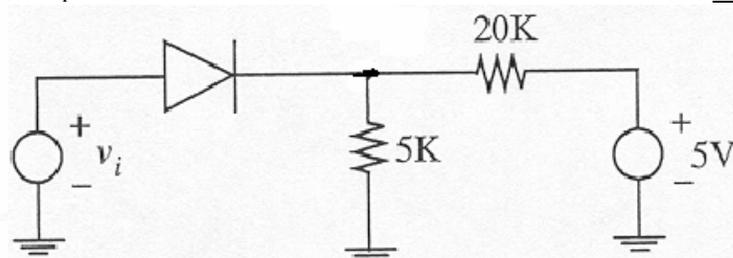
[6 pts.] a) Find V_x when:

a.1 $v_i = 9V$

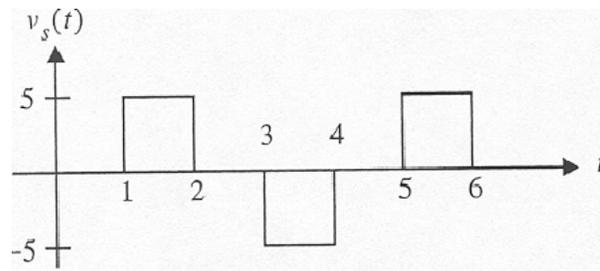
a.1 _____ (V)

a.2 $v_i = -5V$

a.2 _____ (V)

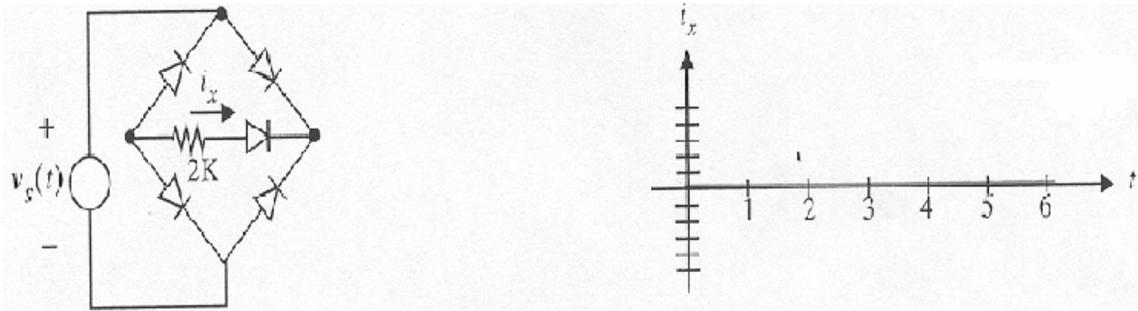


[6 pts.] b)

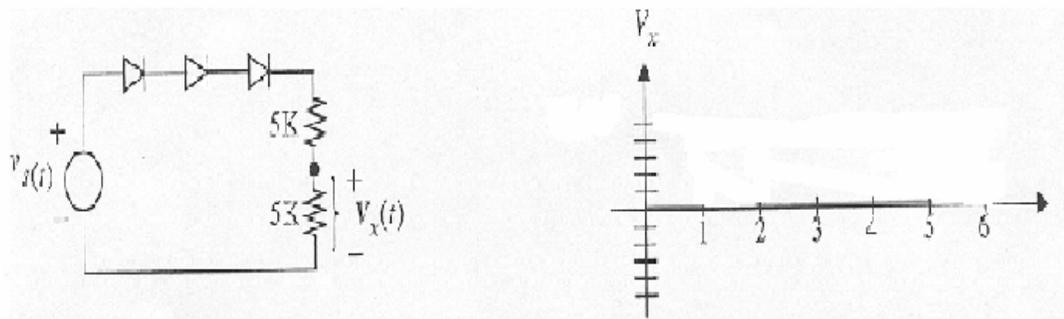


Sketch the unknown i_x or V_x for the following circuits with the inout waveform shown above.

b.1

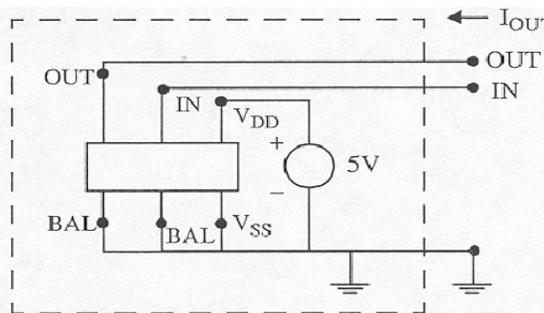


b.2



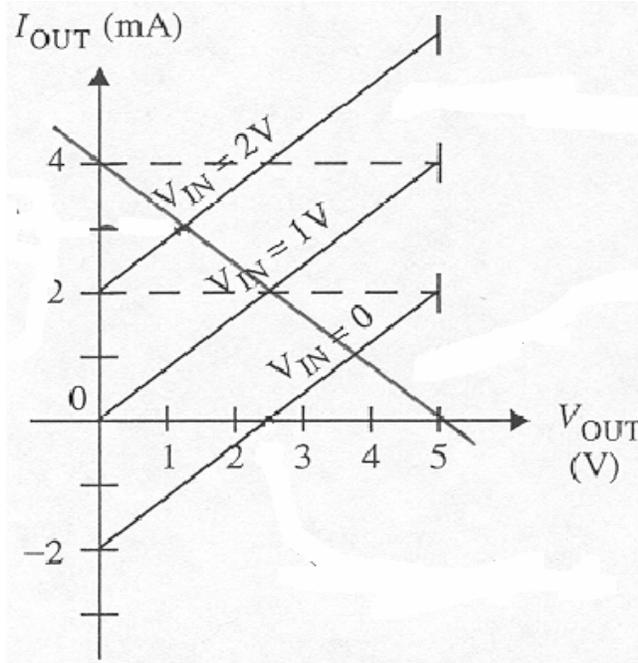
Problem 6 (12 points)

In the lab you encounter a 6-terminal device labeled as follows: One terminal is labeled “Vss”, so you ground it. Another is labeled “V_{DD}”, so you hook it to a +5V supply. Two are labeled “Bal”, not knowing what they might be you simply ground them. The remaining two terminals are labeled “IN” and “OUT”.



So what you now have is essentially a 3-terminal device to study. You proceed to take a series of I-V measurements at one value of v_{in} .

You obtain:



[4 pts.] a) What is the open circuit value of V_{out} for $V_{in} = 0V$?

$V_{out} =$ _____

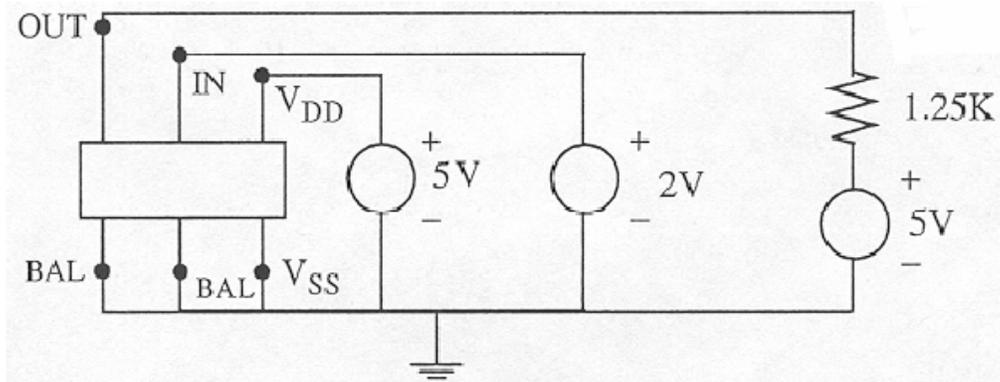
[4 pts.] b) Draw the Thevenin Equivalent circuit of the output for each of the input values given (R_{TH} and V_{TH} may be a function of the input voltage), and fill out the table.

Draw circuit here

V_{IN}	R_T	V_T
0		
1		
2		

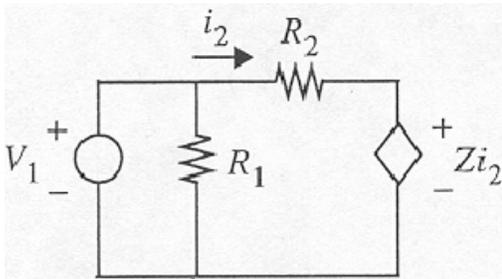
Fill out table

[4 pts.] c) Find I_x (10% accuracy is good enough).



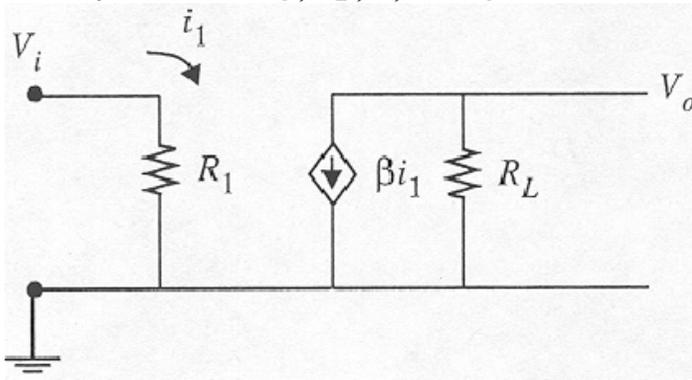
Problem 7 (12 points)

a) Find i_2 in terms of R_1 , R_2 , Z , and V_1 .



$i_2 =$ _____

b) Find V_o in terms of R_1 , R_L , B , and V_i .



$V_o =$ _____

c) In the same circuit as (b), if $R_1 = 10K$, $R_L = 10K$, $B = 100$, and $V_i = 0.01V$, what is V_o ?

$V_o =$ _____

Problem 8 (14 points)

Scientists at Stanford are excited about discovering a new low-mobility semiconductor “Xanium.” The electron mobility in Xanium is $0.5\text{cm}^2/\text{V sec}$ and the saturation drift velocity is 10^6 cm/sec .

They construct a field effect transistor with this material using an insulator of such a thickness that the capacitance per unit area is 10^{-7} coul/cm^2 . The transistor length L is $0.5\mu\text{m}$ and the width W is $10\mu\text{m}$. They find that the threshold voltage is 2.0V . Your job is to predict their experiment results.

a) What is the induced charge per unit area in the channel at a gate-source voltage V_{GS} of 5V ?

$$V_o = \text{_____}(\text{units?})$$

b) What is the source-drain resistance at $V_{GS} = 1\text{V}$?

$$R = \text{_____}(\text{ohms})$$

c) What is the source-drain resistance at $V_{GS} = 5\text{V}$?

$$R = \text{_____}(\text{ohms})$$

d) In a bulk n-type sample of Xanium that is $0.5\mu\text{m}$ long (in the direction of current flow), how large a voltage would be required to observe velocity saturation? (Hint: Do NOT be too surprised by the answer.)

$$V = \text{_____}(\text{V})$$

e) Would velocity saturation be observed in this transistor (for drain voltages of 5V or less)?

Y or N _____

Why? _____